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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/559,773	12/07/2005	Yorinobu Kunimune	8008-1077	5941
466 7590 03/07/2007 YOUNG & THOMPSON			EXAMINER	
745 SOUTH 23		CHAN, EMILY Y		
2ND FLOOR ARLINGTON, VA 22202			ART UNIT	PAPER NUMBER
1110111011, 111 2222			2829	
SHORTENED STATUTORY PERIOD OF RESPONSE		MAIL DATE	DELIVERY MODE	
3 MONTHS		03/07/2007	· PAPER	

Please find below and/or attached an Office communication concerning this application or proceeding.

If NO period for reply is specified above, the maximum statutory period will apply and will expire 6 MONTHS from the mailing date of this communication.

	Application No.	Applicant(s)				
	10/559,773	KUNIMUNE, YORINOBU				
Office Action Summary	Examiner	Art Unit				
	Emily Y. Chan	2829				
The MAILING DATE of this communication app Period for Reply	pears on the cover sheet with the c	orrespondence address				
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING D. Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication. If NO period for reply is specified above, the maximum statutory period or Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be time will apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONE	N. nely filed the mailing date of this communication. D (35 U.S.C. § 133).				
Status		•				
1) Responsive to communication(s) filed on 16 Ja	anuary 2007.					
•	s action is non-final.					
3) Since this application is in condition for allowa						
closed in accordance with the practice under E	Ex parte Quayle, 1935 C.D. 11, 45	53 O.G. 213.				
Disposition of Claims						
4)⊠ Claim(s) <u>1-12</u> is/are pending in the application.						
4a) Of the above claim(s) is/are withdrawn from consideration.						
5) Claim(s) 5 is/are allowed.						
6)⊠ Claim(s) <u>1-4,6-9,11 and 12</u> is/are rejected.						
7)⊠ Claim(s) <u>10</u> is/are objected to.						
8) Claim(s) are subject to restriction and/o	or election requirement.					
Application Papers						
9) The specification is objected to by the Examine	er.					
10)⊠ The drawing(s) filed on <u>16 August 2006</u> is/are: a)⊠ accepted or b)□ objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).						
11) The oath or declaration is objected to by the E	xaminer. Note the attached Office	Action or form PTO-152.				
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of:						
 Certified copies of the priority document 	ts have been received.	•				
2. Certified copies of the priority documents have been received in Application No						
3. Copies of the certified copies of the priority documents have been received in this National Stage						
application from the International Bureau (PCT Rule 17.2(a)).						
* See the attached detailed Office action for a list of the certified copies not received.						
Attachment(s)						
1) Notice of References Cited (PTO-892) 4) Interview Summary (PTO-413)						
2) Notice of Draftsperson's Patent Drawing Review (PTO-948) Paper No(s)/Mail Date						
Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date	5) Motice of Informal I	- atent Application				
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DETAILED ACTION

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

- (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 1. Claims 1-3 and 8 are rejected under 35 U.S.C. 103(a) as being unpatentable over the applicant's admitted prior art (Fig. 5) in view of Cao et al (U S Patent No.5,214,389).

With respect to the claims 1 and 2, the applicant's admitted prior art (Fig. 5) expressly discloses a scanning probe inspection apparatus for detecting anomalies in a passive element out of a plurality of passive elements connected together to form a chain pattern intermittently exposing portions of said chain pattern to a surface of a chip as claimed, comprising a bias voltage supplier, a probe (6) and a scan section.

The applicant's admitted prior art (Fig. 5) does not disclose two probes arranged at a spacing determined by a distance between said exposed portions of said pattern, the bias voltage supplier (5) for supplying the bias voltage between both ends of said chain pattern and a detector for detecting a potential difference between said two probes.

Cao et al ('389) discloses a method and system for semiconductor measurements (see Figs. 1-3) comprising two probes (17,18), bias voltage supply (35) and voltmeter (31) for detecting potential difference between said two probes (see Col.

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4, lines 22-23). Moreover, Cao et al ('389) disclose that their two probes (17,18) are spaced from each other (see Figs. 1-3). Even though Cao et al ('389) do not specify that the size of the distance between the two probes (17,18), it is well known to have the distance between the two probes in any size as desired (see MPEP 2144.04 IV 'CHANGE IN SIZE, SHAPE') Even though Cao et al ('389) do not specify to cause the two probes (17,18) to scan over a surface of the wafer, Cao et al ('389)'s two probes (17,18) still meet the claimed two probes because the manner of operating the probes does not differentiate from the prior art (see MPEP 2114 [R1] "MANNER OF OPERATING THE DEVICE DOES NOT DIFFERENTIATE APPARATUS CLAIM FROM THE PRIOR ART").

Therefore, it would have been obvious to one of ordinary skill in the art at the time the claimed invention was made to be motivated to incorporate the teaching of Cao et al ('389) into the applicants' admitted prior art to produce a scanning probe inspection apparatus as claimed because Cao et al ('389) discloses that their probes can be multi-dimensionally positioned with high -invention, that minimizes penetration depth into a sample surface (see Col. 2, lines 16-18).

With respect to claims 3 and 8, the applicant's admitted prior art (Fig. 5) discloses that passive elements are through-holes (2) and wherein said through holes (2) are coupled to one another such that one upper interconnect line (4) is coupled to an upper end of one through-hole out of adjacent through-holes and one lower interconnect line (3) is coupled to a lower end of said one through-hole out of adjacent through-holes.

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3. Claims 4, 6-7,9 and 11-12 are rejected under 35 U.S.C. 103(a) as being unpatentable over the applicant's admitted prior art in view of Cao et al ('389) as applied to claims 1 -3 above, and further in view of Arnold et al US Patent No. 2003/0062915.

The applicant's admitted prior art in view of Cao et al ('389) do not specific that the probe is shaped with different portions and is coated with a conductive material.

Arnold et al ('915) disclose a probe (see Fig. 3) comprising a thin plate shaped base portion (31), a lever (32) extending from the base portion and a needle portion. Arnold et al ('915) also disclose that the probe is formed by coating with a conductive material (see page 2, paragraph (0023) lines 4-6)). Furthermore, Arnold et al ('915) disclose that the conductive material can be diamonds (see page 1, paragraph (0012) line 10 "such as diamonds").

Therefore, it would have been obvious to one of ordinary skill in the art at the time the claimed invention was made to incorporate the teaching of Arnold et al ('915) into the applicants' admitted prior art in view of Cao et al ('389)'s apparatus for the expected benefit of allowing fabrication of very small, highly reliable contact devices capable of repeated use as disclosed by Arnold et al ('915) (see page 2, paragraph (0023) lines 6-7).

Allowable Subject Matter

Claim 10 is objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

4. Claim 5 is allowed.

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The following is a statement of reasons for the indication of allowable subject

matter:

Claims 10 and 5 are indicated allowable because the prior art in the record do

not teach that a probe needle is so formed as to be inclined from said distal end of said

lever in a direction that said distal end points.

Response to Arguments

Applicant's arguments with respect to claims 1, 3-4 and 6-12 have been

considered but are moot in view of the new ground(s) of rejection.

Conclusion

Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Emily Y. Chan whose telephone number is 571-272-

1956. The examiner can normally be reached on 8:30-5:30.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Ha T Nguyen can be reached on 571-272-1678. The fax phone number for

the organization where this application or proceeding is assigned is 571-273-8300.

HA TRAN NGUYEN SUPERVISORY PATENT EXAMINED

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR.

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EC 3/5/07

HA TRAN NGUYEN
SUPERVISORY PATENT EXAMINED